

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
20 February 2003 (20.02.2003)

PCT

(10) International Publication Number
WO 03/014776 A1

(51) International Patent Classification⁷: **G02B 1/10**

(21) International Application Number: PCT/AU02/01035

(22) International Filing Date: 2 August 2002 (02.08.2002)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
PR 6787 3 August 2001 (03.08.2001) AU

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(81) Designated States (*national*): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, OM, PH, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZM, ZW.

(84) Designated States (*regional*): ARIPO patent (GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

— with international search report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.

(54) Title: SCRATCH MASKING COATINGS FOR OPTICAL SUBSTRATES

(57) Abstract: This invention relates to a reflective coating for a surface of an optical substrate, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the reflective coating to be scratch masking.



WO 03/014776 A1

SCRATCH MASKING COATINGS FOR OPTICAL SUBSTRATES

Field of the Invention

- 5 The present invention relates to scratch masking coatings on optical substrates, together with methods of forming such scratch masking coatings on optical substrates. The present invention also relates to optical substrates having such scratch masking coatings thereon.
- 10 It will become apparent from the following description that the optical substrates are most likely to be optical articles such as ophthalmic lenses, and sunglass lenses in particular. However, it must be appreciated that the invention is not to be limited in its application to only those optical substrates.

15 Background of the Invention

- Coatings are generally applied to optical substrates so as to impart some desired optical characteristic to the optical substrate. For example, an anti-reflection coating might be applied to a surface of an ophthalmic lens so as to
- 20 reduce parasitic reflections that interfere with the vision of the wearer. Such a coating serves to increase the transmission of light through to the wearer and improve the visibility of the wearer's eyes to others. Another example of a coating used to impart a desired optical characteristic to an optical substrate is that of mirror (reflective) coatings. Such coatings might be applied to a surface
- 25 of an ophthalmic lens so as to improve the contrast of viewed images for the wearer, as well as to provide a reduction in transmitted ultra-violet or infra red light. Mirror coatings may also impart a coloured appearance to the optical substrate, which may be desirable for aesthetic purposes.
- 30 Coatings may also be used to provide an improved physical property to a surface of an optical substrate. For example, abrasion resistant coatings might

- 2 -

be applied to a surface of an ophthalmic lens so as to improve the resistance of the surface to mechanical damage, such as scratching.

Scratching of a surface of an ophthalmic lens not only interferes with the vision
5 of the wearer, but it may also result in an article that is less appealing aesthetically. This is particularly the case for lenses that have a mirror coating applied to them. Mirror coatings generally have poor abrasion resistance and as such are easily damaged.

10 A particular deficiency of mirror coatings is that when scratched, the scratches are highly visible due to the colour contrast between the scratches and the mirror coating. The most dramatic example of such a loss in visual appeal is observed with blue mirror coatings. When scratched, such mirror coatings exhibit highly visible purple, pink and yellow scratches. The visibility of the
15 scratches is due to the difference in colour and brightness between the light reflected from the undamaged surface of the mirror coating and the light reflected from the scratch on the surface of the mirror coating.

Mirror coatings are most often applied to the surface of abrasion resistant
20 coatings such as hardcoat layers. However, although the abrasion resistant coating may provide resistance to mechanical damage to the optical substrate, the mirror coating itself may still be easily damaged. Consequently, any damage to the optical substrate will first occur to the surface of the mirror coating, resulting in a reduction in the quality of the vision of the wearer and an optical
25 substrate that has less aesthetic appeal.

A deficiency in the prior art has been the inability to formulate a coating that provides a reduction in the visibility of scratches on the surface of an optical substrate, and in particular, the inability to formulate mirror coatings that provide
30 a reduction in the visibility of scratches on the surface of an optical substrate. It is also desirable to provide a coating with improved resistance to scratching, as

- 3 -

compared to the resistance to scratching of other similar coatings that when damaged show highly visible scratches.

Summary of the Invention

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The present invention provides a reflective coating for a surface of an optical substrate, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of layers selected to cause the coating to be scratch masking.

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The present invention also provides an optical substrate having a reflective coating on a surface thereof, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the coating to be scratch masking.

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The present invention further provides a method for forming a reflective coating on a surface of an optical substrate, the method including the step of depositing a reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the

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reflective coating to be scratch masking.

The present invention arises out of studies into the highly visible nature of scratches to reflective coatings. It has been found that reflective coatings may be produced that are scratch masking by selecting a coating so that the

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intensity and colour of the light reflected from the surface of the optical substrate do not change substantially with changes in the thickness of the coating. Such a coating is said to be "scratch masking".

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In particular, it has been found that for a reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of layers may be selected to cause the reflective coating to be scratch masking.

- 4 -

Various terms that will be used throughout the specification have meanings that will be well understood by a skilled addressee. However, for ease of reference, some of these terms will now be defined.

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The term "reflective coating" as used throughout the specification is to be understood to mean any coating applied to the surface of an optical substrate which functions to reflect a proportion of the incident light thereon. An example of a reflective coating is that commonly referred to in the art as a "mirror
10 coating". It is also to be understood that the term "reflective coating" as used throughout the specification means a coating that may consist of more than one layer.

The term "optical substrate" as used throughout the specification is to be
15 understood to mean any substrate that has the capacity to transmit or reflect light and that may require a reflective coating that is able to reduce the visibility of scratches on a surface of the substrate. The term not only includes optical articles such as ophthalmic lenses and sunglass lenses, but any other type of article that may require a reflective coating that has the capability to reduce the
20 visibility of scratches. For instance, the optical substrate may include any transparent or opaque surface to which a decorative coating may be applied. Where the optical substrate is an optical article such as an ophthalmic lens, the lens may be formed from a variety of different lens materials, including glass, and particularly a number of different polymeric plastic resins. A common
25 material is diethylene glycol bis (allyl carbonate) or CR39 (PPG Industries). Other suitable materials are acrylics, allylics, styrenics, polycarbonates, vinylics, polyesters and the like.

The term "scratches" as used throughout the specification is to be understood to
30 mean any physical damage to the surface of an optical substrate that results in a difference in the colour and/or brightness of light reflected from the damaged surface as compared to the light reflected from the undamaged surface of the

optical substrate.

An optical substrate is said to be "scratch masked" by a coating in accordance with the various forms of the present invention when the reflectance from the
5 coating does not vary substantially in colour when the coating is scratched.

Brief Description of the Figures

Figure 1 illustrates the properties of scratch masking coatings as described in
10 Example 1. Figure 1a represents a simulated plot of reflectance as a function of the light wavelength. Figure 1b represents a simulated plot of colour variation with scratch depth in the CIE 1931 colour space, each point representing a 10 nm step increment in the scratch depth. Figure 1c represents a simulated plot of colour variation with scratch depth using the $\Delta E(\text{CMC } 2:1)$ formula, as a
15 function of the scratch depth.

Figure 2 illustrates the properties of scratch masking coatings as described in Example 2. Figure 2a represents a simulated plot of colour variation with scratch depth in the CIE 1931 colour space, each point representing a 10 nm
20 step increment in the scratch depth. Figure 2b represents a simulated plot using $\Delta E(\text{CMC } 2:1)$ formula, as a function of the scratch depth.

Figure 3 illustrates the properties of scratch masking coatings as described in Example 3. Figure 3a represents a simulated plot of colour variation with
25 scratch depth in the CIE 1931 colour space, each point representing a 10 nm step increment in the scratch depth. Figure 3b represents a simulated plot of colour variation using $\Delta E(\text{CMC } 2:1)$ formula, as a function of the scratch depth.

Figure 4 illustrates the properties of scratch masking coatings as described in
30 Example 4. Figure 4a represents a simulated plot of colour variation with scratch depth in the CIE 1931 colour space, each point representing a 10 nm

- 6 -

step increment in the scratch depth. Figure 4b represents a simulated plot of colour variation using $\Delta E(\text{CMC } 2:1)$ formula, as a function of the scratch depth.

Figure 5 illustrates the properties of scratch masking coatings as described in Example 5. Figure 5a represents a simulated plot of colour variation with scratch depth in the CIE 1931 colour space, each point representing a 10 nm step increment in the scratch depth. Figure 5b represents a simulated plot of colour variation with scratch depth using $\Delta E(\text{CMC } 2:1)$ formula, as a function of the scratch depth.

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Figure 6 illustrates the damage following 75 cycles of the Steelwool test to a standard two layer metallic mirror coating deposited with ion assistance, as compared to the damage to a scratch masking Sky Blue mirror deposited with ion assistance, as described in Example 6.

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General Description of the Invention

As mentioned above, in one form the present invention provides a reflective coating for a surface of an optical substrate, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the reflective coating to be scratch masking.

As discussed previously, scratches to mirror coatings are highly visible because the intensity and colour of the light reflected from a scratch varies from the light normally reflected from the surface of the coating.

In this regard, it will be appreciated that many coatings, particularly those applied to optical substrates, consist of more than one optically transparent layer. A scratch to such a coating may be considered to represent a situation where the light is incident to a surface in which a part (the scratch) of the top layer of the coating is of reduced thickness. A change in the thickness of the top

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- 7 -

layer, as occurs when the coating is damaged, may affect the colour and intensity of the light reflected from the surface of the coating. This change in the colour and intensity of the light may be understood as resulting from a variation in interference recombination.

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The colour and intensity of light reflected from a coating consisting of more than one optical layer will therefore depend on a number of factors, including the wavelength (colour) of the incident light, the number and thickness of the optical layers, and the refractive indices of the respective layers. A change in the thickness of any of the layers, as occurs when the surface is scratched, may result in a change in the intensity and colour of the reflected light from the coating.

The scratch masking properties of the reflective coating of the present invention may be obtained by selecting a coating so that the intensity and colour of the light reflected from the surface of the optical substrate do not change substantially with changes in the thickness of the coating.

To provide a reflective coating that is scratch masking, the number of layers, the refractive index of each layer and/or the thickness of each layer are selected so that the intensity and colour of the light reflected from the coating do not change substantially as the thickness of the coating changes. In particular, to provide a reflective coating that is scratch masking, the reflective coating includes a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of layers selected so as to cause the coating to be scratch masking.

An optical substrate is said to be "scratch masked" by a reflective coating in accordance with the various forms of the present invention when the reflectance from the coating does not vary substantially in colour when the coating is scratched. Preferably, the optical substrate to which the reflective coating is applied is an ophthalmic lens or a sunglass lens.

In determining whether this requirement is met, it should be noted that as scratches are typically not deeper than about 50 nm, scratches up to this depth should be masked by the coating of the present invention. However, in some
5 embodiments of the present invention, scratches with a greater depth may also be masked such that the reflectance from the coating does not vary substantially in colour. In this respect, the broadest threshold for what is considered by the applicant to be an insubstantial variation in colour is represented by a reflected colour shift (ΔE) of 11 or less. More preferably, the
10 threshold is represented by a reflected colour shift (ΔE) of 6 or less.

In relation to the parameter referred to as "a reflected colour shift (ΔE)", the visual appearance of coated optical articles in reflected light can be quantified by measuring the reflectance spectrum in a spectrophotometer. This spectral
15 information may be reduced to three colour coordinates – a "lightness" corresponding primarily to the luminous intensity of the reflected light, and two chromatic attributes, the "hue" and "chroma" corresponding to the general colour (eg. red, blue, green etc.) and its vividness, as detailed in "The Measurement of Appearance", 2nd ed., R.S. Hunter and R.W. Harold, Wiley,
20 New York, 1987. The term "colour" as used here refers to all three coordinates. Perceived variations in appearance may thus be quantified by calculating colour differences or shifts, such as a "CMC colour difference" as developed by the Colour Measurement Committee of the Society of Dyers and Colourists. In this respect, a reflected colour shift of, for example, $\Delta E_{CMC(2:1)}=1$ (which is the limit of
25 acceptability for textiles), has been found by the applicant to be too stringent a tolerance for reflective coatings. Indeed, and as mentioned above, the applicant has observed that reflected colour shifts (ΔE) of up to 11 occurring when a mirror coated lens is scratched are quite acceptable. Preferably, the reflected colour shift (ΔE) of the reflective coating when scratched is 6 or less.

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An alternative method of assessing whether a reflective coating is scratch masking in accordance with the present invention is to determine whether the

- 9 -

colour of the light reflected from a damaged coating varies substantially from the light reflected from the undamaged coating using the CIE 1931 system of colour specification.

- 5 The CIE 1931 system of colour specification allows a given colour to be specified by the amounts of three primary colours required to match the colour. In this way, a colour can be designated a position in a three dimensional plot where each of the primary colours represents an axis. Any given colour may therefore occupy a particular position in three dimensional colour space.
- 10 However, for ease of representation, the three dimensional colour space can be mathematically transformed into a two dimensional graphical representation. In this way, the three primary colours that specify a given colour can be transformed into chromaticity coordinates, x and y , and any given colour will occupy a specific position in a chromaticity diagram.

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- In terms of a chromaticity diagram, a coating will be said to be "scratch masking", and thus, be in accordance with the present invention, if there is not a substantial change in the position in the chromaticity coordinates when the coating is scratched. In particular, the variation in colour for a scratch masking
- 20 coating when scratched will be less than the variation shown for an equivalent non-scratch masking coating. By an equivalent non-scratch masking coating is meant an undamaged coating that has similar colour attributes to the undamaged scratch masking coating. Therefore, for the coatings to be equivalent, the scratch masking coating and the non-scratch masking coating
- 25 will, before being scratched, occupy similar positions in a chromaticity diagram.

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Accordingly, in a preferred form the present invention provides a reflective coating for which the variation in the chromaticity coordinates of the light reflected from the reflective coating when scratched is substantially unchanged.

The lower and higher refractive index layers of the reflective coating in the various forms of the present invention may be formed from any optically suitable

- 10 -

material, such as from one or more optically suitable dielectric materials. Preferably, the optically suitable dielectric material is a metal oxide, a metal fluoride, a metal nitride or diamond-like carbon. More preferably, the dielectric material is selected from one or more of the group consisting of Al_2O_3 , BaTiO_3 , Bi_2O_3 , CeO_2 , Cr_2O_3 , Ga_2O_3 , GeO_2 , Fe_2O_3 , HfO_2 , In_2O_3 , Indium-tin oxide, La_2O_3 , MgO , Nd_2O_3 , Nb_2O_5 , Pr_2O_3 , Sb_2O_3 , Sc_2O_3 , SiO , SiO_2 , SnO_2 , Ta_2O_5 , TiO , TiO_2 , Ti_2O_3 , Ti_3O_5 , WO_3 , Y_2O_3 , Yb_2O_3 , ZnO , ZrO_2 , AlF_3 , BaF_2 , CaF_2 , CdF_2 , CeF_3 , HfF_4 , LaF_3 , LiF , MgF , NaF , Na_3AlF_6 , $\text{Na}_5\text{Al}_3\text{F}_{16}$, NdF_3 , PbF_2 , PrF_3 , SrF_2 , ThF_4 , ZrF_4 , Si_3N_4 , AlN . Polymeric materials or dielectric materials that include dopants of metal compounds may also be used.

In a particularly preferred form, the lower refractive index layer(s) include a silica (SiO_2), and the higher refractive index layer(s) include titanium dioxide (TiO_2) or a combination of titanium dioxide (TiO_2) and a praseodymium oxide (Pr_2O_3).

By a lower refractive index layer in accordance with the various forms of the present invention is meant a layer with refractive index in the range from 1.40 to 1.50. Preferably, the refractive index of a lower refractive index layer(s) is 1.45.

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By a higher refractive index layer in accordance with the present invention is meant a layer with a refractive index in the range from 1.90 to 2.50. Preferably, the refractive index of a higher refractive layer(s) is 2.09.

The scratch masking coating in the various forms of the present invention includes a plurality of layers. Preferably, the scratch masking coating includes 4 or more layers. Most preferably, the scratch masking coating consists of 4 or 5 layers of alternating higher and lower refractive index.

The thickness of the layers of the alternating layers of higher and lower refractive index in the various forms of the present invention is not particularly limited, so long as the thickness is selected to cause the reflective coating to be

- 11 -

scratch masking. In this regard, it should be noted that the thickness of the top layer of the coating does not necessarily correlate with the scratch masking properties of the coating. Top layers which are thinner than the scratch depth may still be scratch masking.

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An optical substrate with a coating in accordance with the present invention may also include one or more additional coatings. Such an additional coating may underlie the scratch masking coating. Examples of such a coating that may underlie the scratch masking coating include impact resistant coatings, abrasion
10 resistant coatings, and adhesion promoting coatings. Preferably, the additional coating is an abrasion resistant coating.

The abrasion resistant coating in the various forms of the present invention may be of any suitable type, but an abrasion resistant coating including siloxane
15 resin with colloidal silica dispersion is preferred. Abrasion resistant layers may be applied by techniques such as chemical vapour deposition (CVD). Preferably the hardcoat may be applied by low temperature plasma enhanced CVD.

Other coatings may also be applied onto the scratch masking coating to impart
20 a desired surface property to the optical article. Preferably, such other coatings are very thin, with a thickness of 5 nm being most preferred. A preferred coating that may be applied onto the scratch masking coating is a hydrophobic coating. Preferably, the hydrophobic coating includes a fluorine polysilazane.

25 Other fluorinated coatings with hydrophobic and/or oleophobic properties may also be used in conjunction with the scratch masking coating. Hydrophilic coatings such as anti-fog coatings may also be used in conjunction with the scratch masking coatings. Preferably these additional coatings overlie the scratch masking coating.

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- 12 -

The use of both an abrasion resistant coating underlying the scratch masking coating and a hydrophobic coating over the scratch masking is particularly preferred.

- 5 Further, a surface of the optical substrate may be subjected to a surface treatment to improve bondability and/or compatability of the scratch masking coating and any additional coating(s). The surface treatment may be selected from one or more of the group consisting of plasma radiation, UV radiation, flame treatment, ion pre-cleaning and laser treatment, including excimer laser
10 treatment.

The layers of the scratch masking coating may be deposited by any suitable means. For example, the layers may be deposited via vacuum deposition, by physical vapour deposition (PVD) using evaporation with or without ion-
15 assistance or by sputtering. Alternatively, the layers may be deposited by chemical vapour deposition (CVD). Preferably, the layers of the scratch masking coating will be deposited by physical vapour deposition.

It has also been determined that reflective coatings in accordance with the
20 present invention show improved resistance to abrasion as compared to a non-scratch masking coating with similar reflectance and colour characteristics.

The abrasion resistance of the reflective coating may be determined by a suitable method known in the art. For example, the abrasion resistance of a
25 reflective coating in accordance with the present invention may be determined by subjecting an optical substrate with a reflective coating thereon to 75 cycles of a Steel Wool test. As will be appreciated, the comparative coating will be applied on a similar lens, with a similar hardcoat and it will have similar reflectance (R) and colour characteristics (x and y) to the scratch masking
30 coating as determined using the CIE 1931 system of colour specification.

- 13 -

The present invention also contemplates optical substrates having scratch masking reflective coatings as discussed above on one or more surfaces of the optical substrate. Accordingly, in a preferred form the present invention provides an optical substrate having a reflective coating on a surface thereof, the
5 reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the coating to be scratch masking.

The present invention further contemplates methods for forming a scratch
10 masking reflective coating as discussed above on a surface of an optical substrate. Accordingly, in another preferred form, the present invention provides a method for forming a reflective coating on a surface of an optical substrate, the method including the step of depositing a reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness
15 and/or number of the layers selected to cause the reflective coating to be scratch masking.

Description of Preferred Embodiments

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The present invention will now be described in relation to various examples of preferred embodiments. However, it must be appreciated that the following description is not to limit the generality of the above description.

25 Example 1

Table 1 illustrates an example of a scratch resistant, night blue reflective (mirror) coating and two comparative coatings with similar reflectance and colour characteristics (as determined using the CIE 1931 colour system). The
30 first comparative coating is a two layer metallic coating. The second comparative coating is a five layer dielectric coating.

The properties of each of the coatings is as calculated using the commercial software package Tfcalc (Thin Film Design software by Software Spectra Inc, Portland Oregon, USA).

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Table 1

Thickness (nm)	2 layer metallic	5 layer dielectric	Scratch - masking
Cr	5	0	0
SiO ₂	295	242	0
Material with n=2.09@550nm	0	50	37
SiO ₂	0	51	57
Material with n= 2.09@550nm	0	32	178
Top SiO ₂	0	20	317
R (%)	10.6	9.9	9.9
x (CIE1931)	0.213	0.201	0.201
y (CIE 1931)	0.203	0.167	0.169

The term "R" represents the predicted percentage luminosity of the light reflected from the coating. Values x and y represent predicted chromaticity coordinates of the reflected light according to the CIE 1931 system of colour specification.

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As can be seen from a plot of the calculated reflectance of each of these coatings as a function of the wavelength of incident light, as shown in Figure 1a, the three mirror coatings all have approximately the same luminous reflectance.

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Superficial scratches of a predetermined depth (nm) were simulated by reducing the thickness of the top layer for each of the described coatings. The resulting reflectance was compared to that of the unscratched surface for each coating. The colour variation as a function of scratch depth is shown in Figure

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1b, where the colour coordinates of the mirror reflection colour are reported in

the CIE 1931 colour space, starting from blue ($x=0.2$, $0.17 < y < 0.20$), each point representing a 10 nm step increment in the scratch depth.

As can be seen from Figure 1b, scratches on the two layer and five layer comparative coatings show a transition from purplish blue to purplish pink with increasing scratch depth. As the scratch depth approaches 50 nm, the scratches appear white. Both comparative coatings show a substantial variation in colour with increasing scratch depth.

However, to the contrary, for the scratch masking coating the scratches appear purplish blue over the range of depths from 0 to 50 nm. This results in the visibility of the scratches being reduced as compared to the comparative two layer and five layer coatings. The variation in the colour for the scratch masking coating with increasing scratch depth is minimal, and the variation is substantially reduced as compared to both of the comparative coatings.

The data of Figure 1b does not include information on the brightness of colour. To illustrate the colour variation more realistically, the colour difference was calculated using $\Delta E(\text{CMC } 2:1)$ formula for a D65 (daylight) illuminant. This system provides a further measure of the ability of the coating to reduce the visibility of scratches. Figure 1c shows the ΔE values for scratches of differing depths for the scratch masking coating and the comparative two layer and comparative five layer coatings. Colour variations (ΔE) up to a value of 6 are barely noticeable, and colour variations up to 11 are acceptable. As can be seen, scratches of 20 nm in depth or greater had ΔE values greater than 11 for the comparative two layer coating. For the comparative five layer coating, scratches greater than 20 nm in depth showed ΔE values approaching the limit of acceptability. However, the scratch masking coating showed ΔE values of 6 or less for scratches up to and including a depth of 50 nm.

Example 2

Table 2 illustrates an example of a scratch resistant, sky blue reflective (mirror) coating and two comparative coatings with similar reflectance and colour characteristics (as determined using the CIE 1931 system of colour specification). The first comparative coating is a two layer metallic coating. The second comparative coating is a five layer dielectric coating.

The properties of each of the coatings is as calculated using the commercial software package Tfcalc (Thin Film Design software by Software Spectra Inc, Portland Oregon, USA).

Table 2

Thickness (nm)	2 layer metallic	5 layer dielectric	Scratch - masking
Cr	5	0	0
SiO ₂	100	73	48.2
Material with n=2.09 @ 550 nm	0	39.9	164.8
SiO ₂	0	75.3	117.3
Material with N=2.09 @ 550 nm	0	14.6	146.6
Top SiO ₂	0	69	327.7
R (%)	7.6	14.4	14.4
x (CIE1931)	0.235	0.230	0.230
y (CIE 1931)	0.223	0.249	0.250

The term "R" represents the predicted percentage luminosity of the light reflected from the coating. Values x and y represent predicted chromaticity coordinates of the reflected light according to the CIE 1931 system of colour specification.

Superficial scratches of a predetermined depth (nm) were simulated by reducing the thickness of the top layer for the scratch masking coating and both

comparative coatings. The resulting reflectance was compared to that of the unscratched surface for each coating. The colour variation as a function of scratch depth is shown in Figure 2a, where the colour coordinates of the mirror reflection colour are reported in the CIE 1931 colour space, starting from light blue ($x=0.23$, $0.22 < y < 0.25$), each point representing a 10 nm step increment in the scratch depth .

As can be seen from Figure 2a, scratches on the two layer comparative coating show a transition from blue to white with increasing scratch depth. The five layer comparative coating shows a transition from blue to purple with increasing scratch depth. Both comparative coatings show a substantial variation in colour with increasing scratch depth.

However, to the contrary, the scratch masking coating does not show a change in the colour of the coating with increasing scratch depth, with the sky blue coating remaining light blue. This results in the visibility of the scratches being reduced as compared to the two layer and five layer comparative coatings. The variation in the colour for the scratch masking coating with increasing scratch depth is minimal, and substantially reduced as compared to both of the comparative coatings.

The data of Figure 2b does not include information on the brightness of colour, To illustrate the colour difference more realistically, the colour difference was calculated using $\Delta E(\text{CMC } 2:1)$ formula for a D65 (daylight) illuminant. This system provides a further measure of the ability of the coating to reduce the visibility of scratches. Figure 2b shows the ΔE values for scratches of differing depths for the scratch masking coating and the comparative two layer and comparative five layer coatings. Colour variations (ΔE) up to a value of 6 are barely noticeable, and colour variations up to 11 are acceptable. As can be seen, scratches of 20 nm in depth or greater had ΔE values greater than 11 for the comparative two layer coating. For the comparative five layer coating, scratches greater than 20 nm in depth showed ΔE values approaching the limit

of acceptability. However, the scratch masking coating showed ΔE values of 6 or less for scratches up to and including a depth of 50 nm.

Example 3

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Table 3 illustrates an example of a scratch resistant, black reflective (mirror) coating and two comparative coatings with similar reflectance and colour characteristics (as determined using the CIE 1931 system of colour specification). The first comparative coating is a two layer metallic coating. The

10 second comparative coating is a five layer dielectric coating.

The properties of each of the coatings is as calculated using the commercial software package Tfcalc (Thin Film Design software by Software Spectra Inc, Portland Oregon, USA).

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Table 3

Thickness (nm)	2 layer metallic	5 layer dielectric	Scratch - masking
Cr	5	0	0
SiO ₂	70	0	50
Material with n=2.09@550nm	0	17.8	10
SiO ₂	0	39.6	54.9
Material with n= 2.09@550nm	0	50.9	25.2
Top SiO ₂	0	187	21.7
R (%)	7.6	15.6	13.4
x (CIE1931)	0.355	0.307	0.323
y (CIE 1931)	0.325	0.316	0.320

The term "R" represents the predicted percentage luminosity of the light reflected from the coating. Values x and y represent predicted chromaticity coordinates of the reflected light according to the CIE 1931 system of colour specification.

20

Superficial scratches of a predetermined depth (nm) were simulated by reducing the thickness of the top layer for each of the described coatings. The resulting reflectance was compared to that of the unscratched surface for each coating. The colour variation as a function of scratch depth is shown in Figure 3a, where the colour coordinates of the mirror reflection colour are reported in the CIE 1931 colour space, starting from colourless-white (which appears as a black mirror on a dark tinted lens) ($0.30 < x < 0.36$, $0.31 < y < 0.33$), each point representing a 10 nm step increment in the scratch depth.

10

As can be seen from Figure 3a, scratches applied to the comparative two layer coating show a transition from colourless to light pink with increasing scratch depth, while the comparative five layer coating shows a transition from colourless to light blue with increasing scratch depth. There was substantial variation in colour with increasing scratch depth for the comparative five layer coating, with the comparative two layer coating showing less variation than the comparative five layer with increasing scratch depth.

15

However, to the contrary, for the scratch masking coating the scratches appear colourless over the range of depths from 0 to 50 nm. This results in the visibility of the scratches being reduced as compared to the comparative two layer and five layer coatings. The variation in the colour for the scratch masking coating with increasing scratch depth is minimal and substantially reduced with respect to the comparative two layer coating in particular.

20

25

The data of Figure 3b does not include information on the brightness of colour. To illustrate the colour variation more realistically, the colour difference was calculated using $\Delta E(\text{CMC } 2:1)$ formula for a D65 illuminant. This system provides a further measure of the ability of the coating to reduce the visibility of scratches. Figure 3b shows the ΔE values for scratches of differing depths for the scratch masking coating and the comparative two layer and comparative five layer coatings. Colour variations (ΔE) up to a value of 6 are barely

30

- 20 -

noticeable, and colour variations up to 11 are acceptable. As can be seen, scratches of 10 nm in depth or greater had ΔE values greater than 11 for the comparative two layer coating. For the comparative five layer coating, scratches greater than 30 nm in depth showed ΔE values approaching the limit of acceptability. However, the scratch masking coating showed ΔE values of 11 or less for scratches up to and including a depth of 50 nm.

Example 4

Table 4 illustrates an example of a scratch resistant, silver reflective (mirror) coating and two comparative coatings with similar reflectance and colour characteristics (as determined using the CIE system of colour specification). The first comparative coating is a two layer metallic coating. The second comparative coating is a two layer dielectric coating.

15

The properties of each of the coatings is as calculated using the commercial software package Tfcalc (Thin Film Design software by Software Spectra Inc, Portland Oregon, USA).

Table 4

Thickness (nm)	2 layer metallic	2 layer dielectric	Scratch - masking
Cr	5	0	0
SiO ₂	10	91.8	20
Material with n=2.09@550nm	0	61.4	35.7
SiO ₂	0	0	92.2
Material with n= 2.09@550nm	0	0	48.4
Top SiO ₂	0	0	50
R (%)	26.8	27.8	32.9
x (CIE1931)	0.322	0.323	0.301
y (CIE 1931)	0.322	0.331	0.327

20

R represents the predicted percentage luminosity of the light reflected from the coating. Values x and y represent predicted chromaticity coordinates of the reflected light according to the CIE 1931 system of colour specification.

5 Superficial scratches of a predetermined depth (nm) were simulated by reducing the thickness of the top layer for each of the described coatings. The resulting reflectance was compared to that of the unscratched surface for each coating. The colour variation as a function of scratch depth is shown in Figure 4a, where the colour coordinates of the mirror reflection colour are reported in
10 the CIE 1931 colour space, starting from colourless-white (which appears as a silver mirror on a dark tinted lens when the reflection is typically over 20%) ($0.30 < x < 0.32$, $0.32 < y < 0.33$), each point representing a 10 nm step increment in the scratch depth.

15 As can be seen from Figure 4a, the colour range for scratches applied to both the comparative two layer coatings is wider than the colour range for scratches applied to the scratch-masking coating. This results in the visibility of the scratches on the scratch masking coating being reduced as compared to the two layer metallic coating and the two layer dielectric coating.

20

The data of Figure 4a does not include information on the brightness of colour. To illustrate the colour variation more realistically, the colour difference was calculated using $\Delta E(\text{CMC } 2:1)$ formula for a D65 (daylight) illuminant. This system provides a further measure of the ability of the coating to reduce the
25 visibility of scratches. Figure 4b shows the ΔE values for scratches of differing depths for the scratch masking coating and both of the comparative two layer coatings. Colour variations (ΔE) up to a value of 6 are barely noticeable, and colour variations up to 11 are acceptable. As can be seen, scratches of 20 nm in depth or greater had ΔE values greater than 11 for the comparative two layer
30 metallic coating. For the comparative two layer dielectric coating, scratches greater than 30 nm in depth showed ΔE values above the limit of acceptability.

- 22 -

However, the scratch masking coating showed ΔE values of 11 or less for scratches up to and including a depth of 50 nm.

Example 5

5

Table 5 illustrates an example of a scratch resistant, bronze reflective (mirror) coating and a comparative two layer metallic coating with similar reflectance and colour characteristics (as determined using the CIE 1931 system of colour specification).

10

The properties of each of the coatings is as calculated using the commercial software package Tfcalc (Thin Film Design software by Software Spectra Inc, Portland Oregon, USA).

15

Table 5

Thickness (nm)	2 layer metallic	Scratch - masking
Cr	5	0
SiO ₂	200	0
Material with n=2.09 @ 550 nm	0	6.3
SiO ₂	0	37.0
Material with n=2.09 @ 550 nm	0	75.9
Top SiO ₂	0	36.8
R	25.9	13.7
x (CIE1931)	0.382	0.399
y (CIE 1931)	0.40	0.396

The term "R" represents the predicted percentage luminosity of the light reflected from the coating. Values x and y represent predicted chromaticity coordinates of the reflected light according to the CIE 1931 system of colour specification.

20

Superficial scratches of a predetermined depth (nm) were simulated by reducing the thickness of the top layer for each of the described coatings. The resulting reflectance was compared to that of the unscratched surface for each coating. The colour variation as a function of scratch depth is shown in Figure 5b, where the colour coordinates of the mirror reflection colour are reported in the CIE 1931 colour space, starting from bronze ($0.38 < x < 0.40$, $0.39 < y < 0.40$), each point representing a 10 nm step increment in the scratch depth.

As can be seen from Figure 5a, the colour range for scratches applied to the comparative two layer coating is wider than the colour range for scratches applied to the scratch-masking coating. This demonstrates that the visibility of the scratches on the scratch masking coating are reduced as compared to the comparative two layer metallic coating.

The data of Figure 5a does not include information on the brightness of colour. To illustrate the colour variation more realistically, the colour difference was calculated using $\Delta E(\text{CMC } 2:1)$ formula for a D65 illuminant. This system provides a further measure of the ability of the coating to reduce the visibility of scratches. Figure 5b shows the ΔE values for scratches of differing depths for the scratch masking coating and the comparative two layer metallic coating. Colour variations (ΔE) up to a value of 6 are barely noticeable, and colour variations up to 11 are acceptable. As can be seen, scratches of 20 nm in depth or greater had ΔE values greater than 11 for the comparative two layer metallic coating. However, the scratch masking coating showed ΔE values of 11 or less for scratches up to and including a depth of 30 nm.

Example 6

The scratch masking coatings described in Examples 1 to 5 were deposited experimentally on hardcoated CR39 lenses using ion-assisted evaporation.

- 24 -

Table 6 illustrates the structure and composition of each of these scratch-masking mirror coatings.

Table 6

Thickness (nm)	Sky Blue	Black	Silver	Bronze	Night Blue
SiO ₂	48.2	50	20	0	0
n=2.09@550nm	164.8	10	35.7	6.3	37
SiO ₂	117.3	54.9	92.2	37	57
n=2.09@550nm	146.6	25.2	48.4	75.9	178
Top SiO ₂	327.7	21.7	50	36.8	317

5

Two further comparative coatings were also tested. The first comparative coating was a two layer metallic Sky Blue mirror coating deposited on a similar lens with ion beam deposition. The second comparative coating was a two layer metallic Sky Blue mirror coating deposited on a similar lens without ion beam assistance.

10

To test the abrasion resistance of each of the mirror coatings, Steel Wool tests were performed by rubbing a Steelwool pad under a constant charge for 75 cycles. The surface damage to each coating was visually assessed and given a star ratio according to test standards (5 ★ = almost no scratches; 0 ★ = heavily scratched)

15

The abrasion resistance for each of the scratch masking coatings, and the abrasion resistance of both the comparative two layer metallic coatings, as determined by averaging of the results of the tests for at least 2 lenses, is shown in Table 7:

20

25

- 25 -

Table 7

	Steelwool
Scratch-masking Sky Blue	▧ ▧ ▧ ▧ ▧
Scratch-masking Black	▧ ▧ ▧ ▧
Scratch-masking Bronze	▧ ▧ ▧ ▧
Scratch-masking Silver	▧ ▧ ▧
Scratch-masking Night Blue	▧ ▧ ▧
2 layer metallic black mirror (with ion-assistance)	▧
2 layer metallic black mirror (without ion-assistance)	▧

The results obtained using the Steelwool test show that the scratch masking mirror coatings have good to excellent abrasion resistance, and each coating was significantly improved over both the comparative two layer metallic coatings. Surface damage to the scratch masking mirror coatings after the Steelwool test is barely visible. Scratch masking mirrors are significantly more wear resistant than the comparative two layer metallic mirror coatings.

As expected, the scratches applied to the scratch-masking coatings did not exhibit any significant colour changes. However, the scratches applied to both the 2 layer mirrors did exhibit noticeable colour changes. This difference is illustrated in Figure 6 for the case of scratches resulting after the Steelwool test to the scratch masking sky blue mirror coating, as compared to the scratches applied to the comparative 2 layer metallic sky blue mirror coating. Scratches to the comparative 2 layer metallic coating are yellow in colour and therefore highly visible. However, scratches to the scratch masking sky blue coating are blue and therefore less visible.

Finally, it will be appreciated that there may be other variations and modifications to the methods described herein that are also within the scope of the present invention.

Claims:

1. A reflective coating for a surface of an optical substrate, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the reflective coating to be scratch masking.
2. A reflective coating according to claim 1, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 11 or less.
3. A reflective coating according to claim 1, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 6 or less.
4. A reflective coating according to claim 1, wherein the variation in the chromaticity coordinates of the light reflected from the reflective coating when scratched is substantially unchanged.
5. A reflecting coating according to any one of claims 1 to 4, wherein the refractive index of the layer or layers of lower refractive index is in the range 1.40 – 1.50.
6. A reflective coating according to claim 5, wherein the refractive index of the layer or layers of lower refractive index is 1.45.
7. A reflective coating according to any one of claims 1 to 6, wherein the refractive index of the layer or layers of higher refractive index is in the range 1.90 to 2.50.
8. A reflective coating according to claim 7, wherein the refractive index of the layer or layers of higher refractive index is 2.09.

- 27 -

9. A reflective coating according to any one of claims 1 to 8, wherein the reflective coating includes four or more layers of alternating higher and lower refractive index.
- 5 10. A reflective coating according to claim 9, wherein the reflective coating consists of 4 layers of alternating higher and lower refractive index.
11. A reflective coating according to claim 9, wherein the reflective coating consists of 5 layers of alternating higher and lower refractive index.
- 10 12. A reflective coating according to any one of claims 1 to 11, wherein the layers are formed from one or more optically suitable dielectric materials.
13. A reflective coating according to claim 12, wherein the dielectric material
15 is a metal oxide, a metal fluoride, a metal nitride or diamond-like carbon.
14. A reflective coating according to claim 13, wherein the dielectric material is selected from the group consisting of Al_2O_3 , BaTiO_3 , Bi_2O_3 , CeO_2 , Cr_2O_3 , Ga_2O_3 , GeO_2 , Fe_2O_3 , HfO_2 , In_2O_3 , Indium-tin oxide, La_2O_3 , MgO , Nd_2O_3 , Nb_2O_5 ,
20 Pr_2O_3 , Sb_2O_3 , Sc_2O_3 , SiO , SiO_2 , SnO_2 , Ta_2O_5 , TiO , TiO_2 , Ti_2O_3 , Ti_3O_5 , WO_3 , Y_2O_3 , Yb_2O_3 , ZnO , ZrO_2 , AlF_3 , BaF_2 , CaF_2 , CdF_2 , CeF_3 , HfF_4 , LaF_3 , LiF , MgF , NaF , Na_3AlF_6 , $\text{Na}_5\text{Al}_3\text{F}_{16}$, NdF_3 , PbF_2 , PrF_3 , SrF_2 , ThF_4 , ZrF_4 , Si_3N_4 , and AlN .
15. A reflective coating according to claim 14, wherein the layer or layers of
25 lower refractive index include SiO_2 .
16. A reflective coating according to claims 14 or 15, wherein the layer or layers of higher refractive index include TiO_2 or a combination of TiO_2 and Pr_2O_3 .

- 28 -

17. A reflective coating according to any one of claims 1 to 16, wherein the reflective coating is formed by vacuum deposition, physical vapour deposition, or chemical vapour deposition.
- 5 18. A reflective coating according to claim 17, wherein the reflective coating is formed by physical vapour deposition.
19. A reflective coating according to any one of claims 1 to 18, wherein the optical substrate further includes one or more additional coatings selected from
10 the group consisting of an abrasion resistant coating, an impact resistant coating, an adhesion promoting coating, a hydrophobic coating, an oleophobic coating, or a hydrophilic coating.
20. A reflective coating according to claim 19, wherein the additional coating
15 is an abrasion resistant coating.
21. A reflective coating according to claim 20, wherein the abrasion resistant coating is deposited by chemical vapour deposition.
- 20 22. A reflective coating according to claim 21, wherein the abrasion resistant coating is deposited by low temperature plasma enhanced chemical vapour deposition.
23. A reflective coating according to any one of claims 20 to 22, wherein the
25 abrasion resistant coating includes a siloxane resin with colloidal silica.
24. A reflective coating according to any one of claims 20 to 23, wherein the abrasion resistant coating underlies the reflective coating.
- 30 25. A reflective coating according to claim 19, wherein the additional coating is a hydrophobic coating.

- 29 -

26. A reflective coating according to claim 25, wherein the hydrophobic coating includes a fluorine polysilazine.

27. A reflective coating according to claims 25 or 26, wherein the
5 hydrophobic coating overlies the reflective coating.

28. A reflective coating according to any one of claims 1 to 27, wherein a surface of the optical substrate is subjected to a surface treatment to improve bondability and/or compatability.

10

29. A reflective coating according to claim 28, wherein the surface treatment is selected from one or more of the group consisting of plasma radiation, UV radiation, flame treatment, ion pre-cleaning and laser treatment, including excimer laser treatment.

15

30. A reflective coating according to any one of claims 1 to 29, wherein the reflective coating shows improved resistance to abrasion as compared to a non-scratch masking coating with similar reflectance and colour characteristics.

20 31. An optical substrate having a reflective coating of a surface thereof, the reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the reflective coating to be scratch masking.

25 32. An optical substrate according to claim 31, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 11 or less.

33. An optical substrate according to claim 31, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 6 or less.

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- 30 -

34. An optical substrate according to claim 31, wherein the variation in the chromaticity coordinates of the light reflected from the reflective coating when scratched is substantially unchanged.
- 5 35. An optical substrate according to any one of claims 31 to 34, wherein the refractive index of the layer or layers of lower refractive index is in the range 1.40 – 1.50.
- 10 36. An optical substrate according to claim 35, wherein the refractive index of the layer or layers of lower refractive index is 1.45.
- 15 37. An optical substrate according to any one of claims 31 to 36, wherein the refractive index of the layer or layers of higher refractive index is in the range 1.90 to 2.50.
38. An optical substrate according to claim 37, wherein the refractive index of the layer or layers of higher refractive index is 2.09.
- 20 39. An optical substrate according to any one of claims 31 to 38, wherein the reflective coating includes four or more layers of alternating higher and lower refractive index.
- 25 40. An optical substrate according to claim 39, wherein the reflective coating consists of 4 layers of alternating higher and lower refractive index.
41. An optical substrate according to claim 39, wherein the reflective coating consists of 5 layers of alternating higher and lower refractive index.
- 30 42. An optical substrate according to any one of claims 31 to 41, wherein the layers are formed from one or more optically suitable dielectric materials.

- 31 -

43. An optical substrate according to claim 42, wherein the dielectric material is a metal oxide, a metal fluoride, a metal nitride or diamond-like carbon.

44. An optical substrate according to claim 43, wherein the dielectric material
5 is selected from the group consisting of Al_2O_3 , BaTiO_3 , Bi_2O_3 , CeO_2 , Cr_2O_3 , Ga_2O_3 , GeO_2 , Fe_2O_3 , HfO_2 , In_2O_3 , Indium-tin oxide, La_2O_3 , MgO , Nd_2O_3 , Nb_2O_5 , Pr_2O_3 , Sb_2O_3 , Sc_2O_3 , SiO , SiO_2 , SnO_2 , Ta_2O_5 , TiO , TiO_2 , Ti_2O_3 , Ti_3O_5 , WO_3 , Y_2O_3 , Yb_2O_3 , ZnO , ZrO_2 , AlF_3 , BaF_2 , CaF_2 , CdF_2 , CeF_3 , HfF_4 , LaF_3 , LiF , MgF , NaF , Na_3AlF_6 , $\text{Na}_5\text{Al}_3\text{F}_6$, NdF_3 , PbF_2 , PrF_3 , SrF_2 , ThF_4 , ZrF_4 , Si_3N_4 , and AlN .

10

45. An optical substrate according to claim 44, wherein the layer or layers of lower refractive index include SiO_2 .

46. An optical substrate according to claims 44 or 45, wherein the layer or
15 layers of higher refractive index include TiO_2 or a combination of TiO_2 and Pr_2O_3 .

47. An optical substrate according to any one of claims 31 to 46, wherein the reflective coating is formed by vacuum deposition, physical vapour deposition,
20 or chemical vapour deposition.

48. An optical substrate according to claim 47, wherein the reflective coating is formed by physical vapour deposition.

25 49. An optical substrate according to any one of claims 31 to 48, wherein the optical substrate further includes one or more additional coatings selected from the group consisting of an abrasion resistant coating, an impact resistant coating, an adhesion promoting coating, a hydrophobic coating, an oleophobic coating, or a hydrophilic coating.

30

50. An optical substrate according to claim 49, wherein the additional coating is an abrasion resistant coating.

- 32 -

51. An optical substrate according to claim 50, wherein the abrasion resistant coating is deposited by chemical vapour deposition.
52. An optical substrate according to claim 51, wherein the abrasion resistant
5 coating is deposited by low temperature plasma enhanced chemical vapour deposition.
53. An optical substrate according to any one of claims 50 to 52, wherein the abrasion resistant coating includes a siloxane resin with colloidal silica.
- 10 54. An optical substrate according to any one of claims 50 to 53, wherein the abrasion resistant coating underlies the reflective coating.
55. An optical substrate according to claim 49, wherein the additional coating
15 is a hydrophobic coating.
56. An optical substrate according to claim 55, wherein the hydrophobic coating includes a fluorine polysilazine.
- 20 57. An optical substrate according to claims 55 or 56, wherein the hydrophobic coating overlies the reflective coating.
58. An optical substrate according to any one of claims 31 to 57, wherein a surface of the optical substrate is subjected to a surface treatment to improve
25 bondability and/or compatability.
59. An optical substrate according to claim 58, wherein the surface treatment is selected from one or more of the group consisting of plasma radiation, UV radiation, flame treatment, ion pre-cleaning and laser treatment, including
30 excimer laser treatment.

60. An optical substrate according to any one of claims 31 to 59, wherein the reflective coating shows improved resistance to abrasion as compared to a non-scratch masking coating with similar reflectance and colour characteristics.
- 5 61. A method for forming a reflective coating on a surface of an optical substrate, the method including the step of depositing a reflective coating including a plurality of layers of alternating higher and lower refractive index, the thickness and/or number of the layers selected to cause the reflective coating to be scratch masking.
- 10 62. A method according to claim 61, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 11 or less.
63. A method according to claim 61, wherein the variation in reflected colour shift (ΔE) of the reflective coating when scratched is 6 or less.
- 15 64. A method according to claim 61, wherein the variation in the chromaticity coordinates of the light reflected from the reflective coating when scratched is substantially unchanged.
- 20 65. A method according to any one of claims 61 to 64, wherein the refractive index of the layer or layers of lower refractive index is in the range 1.40 – 1.50.
66. A method according to claim 65, wherein the refractive index of the layer or layers of lower refractive index is 1.45.
- 25 67. A method according to any one of claims 61 to 66, wherein the refractive index of the layer or layers of higher refractive index is in the range 1.90 to 2.50.
- 30 68. A method according to claim 67, wherein the refractive index of the layer or layers of higher refractive index is 2.09.

- 34 -

69. A method according to any one of claims 61 to 68, wherein the reflective coating includes four or more layers of alternating higher and lower refractive index.

5 70. A method according to claim 69, wherein the reflective coating consists of 4 layers of alternating higher and lower refractive index.

71. A method according to claim 69, wherein the reflective coating consists of 5 layers of alternating higher and lower refractive index.

10

72. A method according to any one of claims 61 to 71, wherein the layers are formed from one or more optically suitable dielectric materials.

15 73. A method according to claim 72, wherein the dielectric material is a metal oxide, a metal fluoride, a metal nitride or diamond-like carbon.

74. A method to claim 73, wherein the dielectric material is selected from the group consisting of Al_2O_3 , BaTiO_3 , Bi_2O_3 , CeO_2 , Cr_2O_3 , Ga_2O_3 , GeO_2 , Fe_2O_3 , HfO_2 , In_2O_3 , Indium-tin oxide, La_2O_3 , MgO , Nd_2O_3 , Nb_2O_5 , Pr_2O_3 , Sb_2O_3 , Sc_2O_3 ,
20 SiO , SiO_2 , SnO_2 , Ta_2O_5 , TiO , TiO_2 , Ti_2O_3 , Ti_3O_5 , WO_3 , Y_2O_3 , Yb_2O_3 , ZnO , ZrO_2 , AlF_3 , BaF_2 , CaF_2 , CdF_2 , CeF_3 , HfF_4 , LaF_3 , LiF , MgF , NaF , Na_3AlF_6 , $\text{Na}_5\text{Al}_3\text{F}_6$, NdF_3 , PbF_2 , PrF_3 , SrF_2 , ThF_4 , ZrF_4 , Si_3N_4 , and AlN .

25 75. A method according to claim 74, wherein the layer or layers of lower refractive index include SiO_2 .

76. A method according to claims 74 or 75, wherein the layer or layers of higher refractive index include TiO_2 or a combination of TiO_2 and Pr_2O_3 .

30 77. A method according to any one of claims 61 to 76, wherein the reflective coating is formed by vacuum deposition, physical vapour deposition, or chemical vapour deposition.

78. A method according to claim 77, wherein the reflective coating is formed by physical vapour deposition.

5 79. A method according to any one of claims 61 to 78, wherein the optical substrate further includes one or more additional coatings selected from the group consisting of an abrasion resistant coating, an impact resistant coating, an adhesion promoting coating, a hydrophobic coating, an oleophobic coating, or a hydrophilic coating.

10

80. A method according to claim 79, wherein the additional coating is an abrasion resistant coating.

15 81. A method according to claim 80, wherein the abrasion resistant coating is deposited by chemical vapour deposition.

82. A method according to claim 81, wherein the abrasion resistant coating is deposited by low temperature plasma enhanced chemical vapour deposition.

20 83. A method according to any one of claims 80 to 82, wherein the abrasion resistant coating includes a siloxane resin with colloidal silica.

84. A method according to any one of claims 80 to 83, wherein the abrasion resistant coating underlies the reflective coating.

25

85. A method according to claim 79, wherein the additional coating is a hydrophobic coating.

30 86. A method according to claim 85, wherein the hydrophobic coating includes a fluorine polysilazine.

- 36 -

87. A method according to claims 85 or 86, wherein the hydrophobic coating overlies the reflective coating.

5 88. A method according to any one of claims 61 to 87, wherein a surface of the optical substrate is subjected to a surface treatment to improve bondability and/or compatability.

89. A method according to claim 88, wherein the surface treatment is selected from one or more of the group consisting of plasma radiation, UV
10 radiation, flame treatment, ion pre-cleaning and laser treatment, including excimer laser treatment.

90. A method according to any one of claims 61 to 89, wherein the reflective coating shows improved resistance to abrasion as compared to a non-scratch
15 masking coating with similar reflectance and colour characteristics.

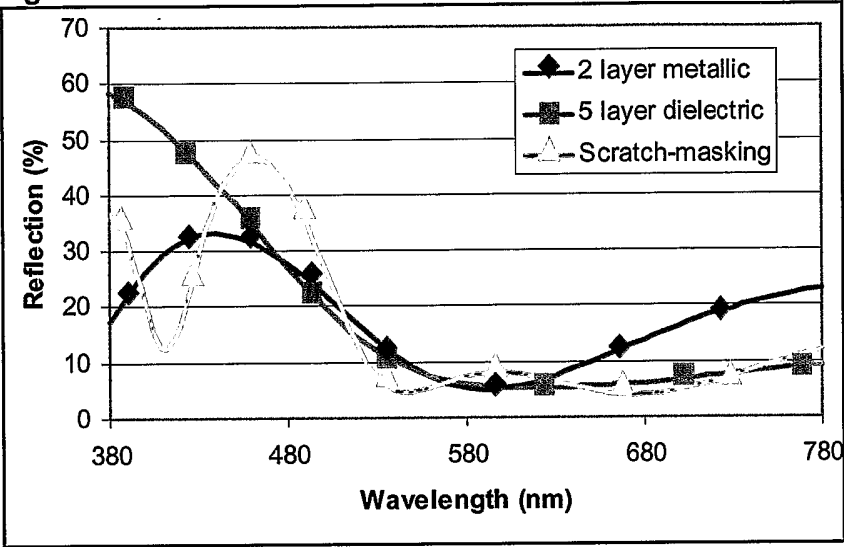
91. A reflective coating according to any one of claims 1 to 30, wherein the optical substrate is an ophthalmic lens or a sunglass lens.

20 92. An optical substrate according to any one of claims 31 to 60, wherein the optical is an ophthalmic lens or sunglass lens.

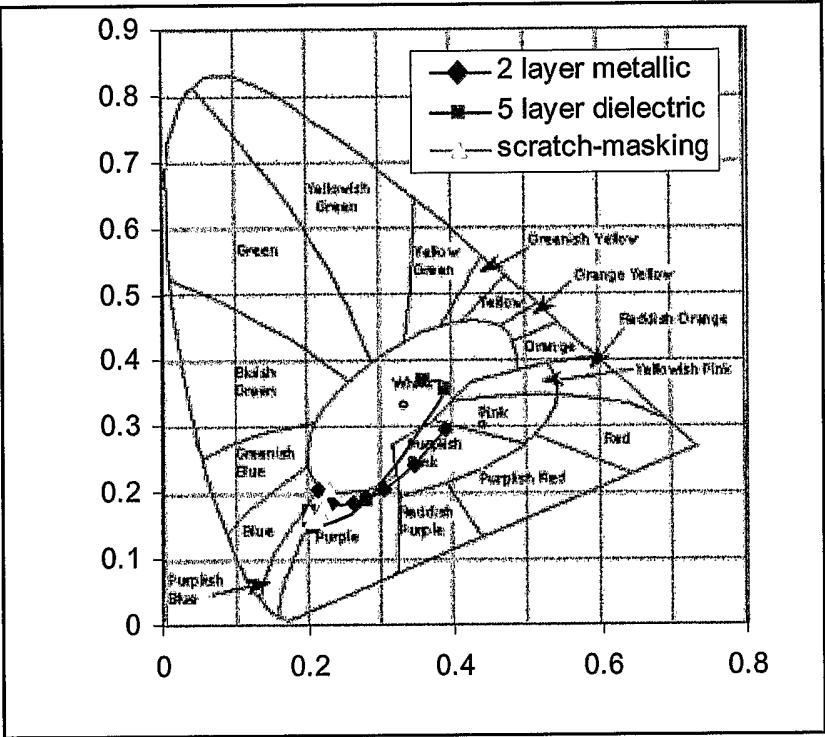
93. A method according to any one of claims 61 to 90, wherein the optical substrate is an ophthalmic lens or a sunglass lens.
25

Figure 1 1/6

(a)



(b)



(c)

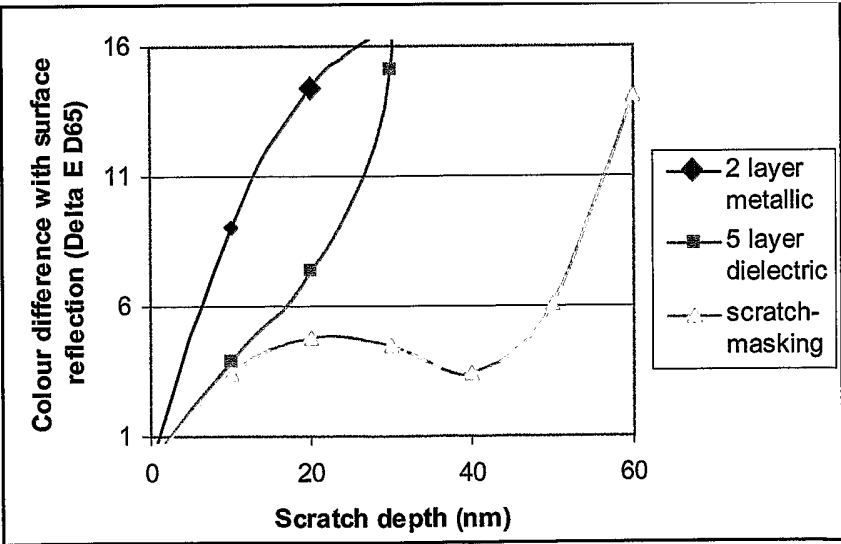


Figure 3

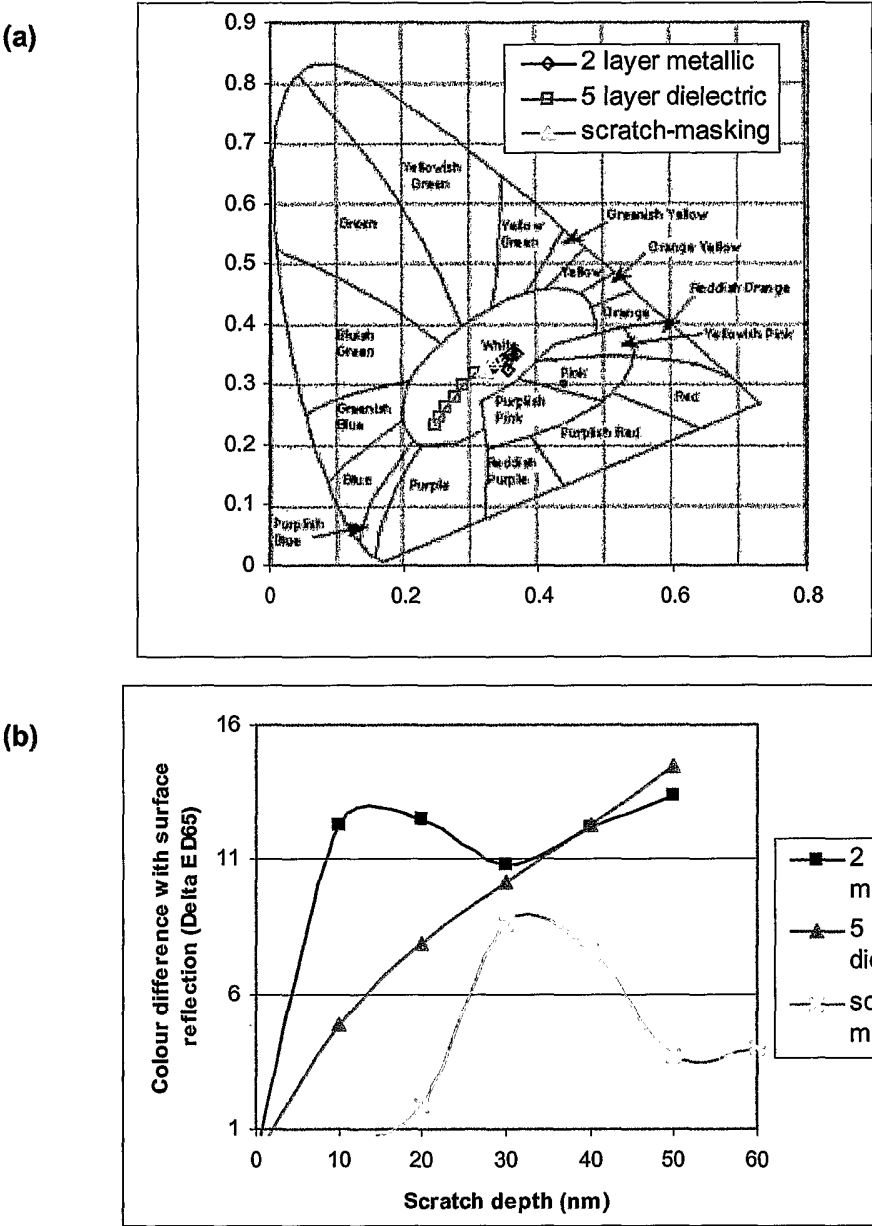
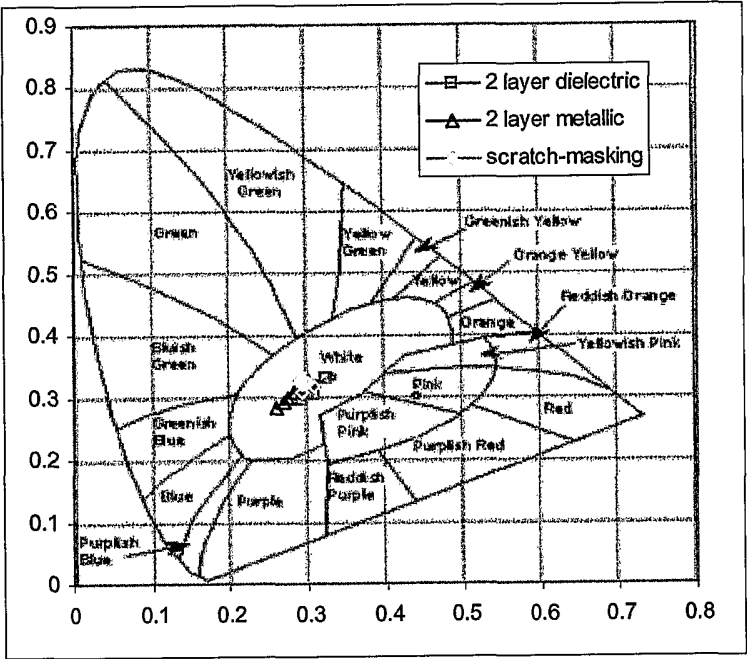


Figure 4

(a)



(b)

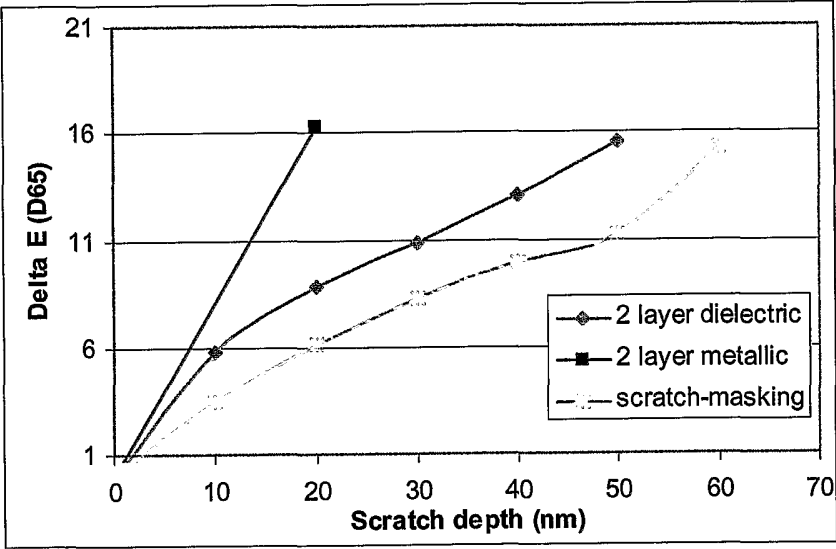
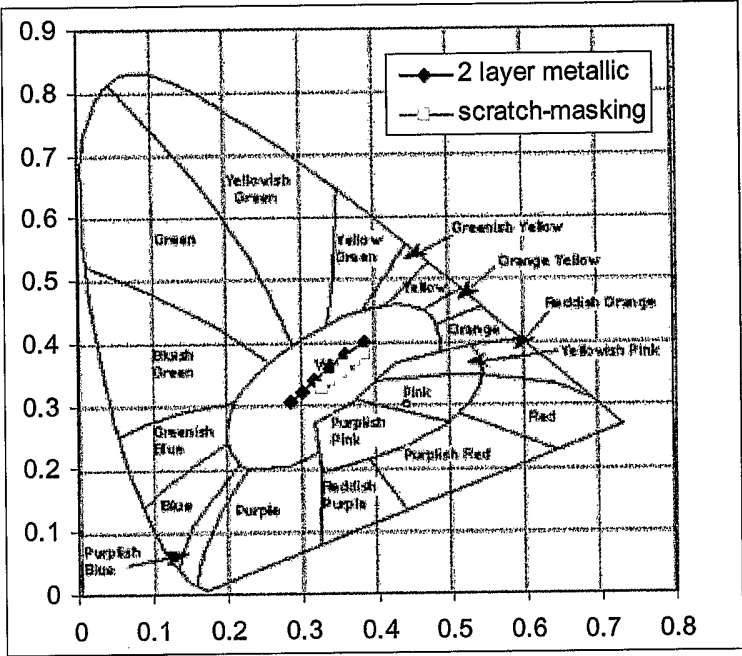


Figure 5

(a)



(b)

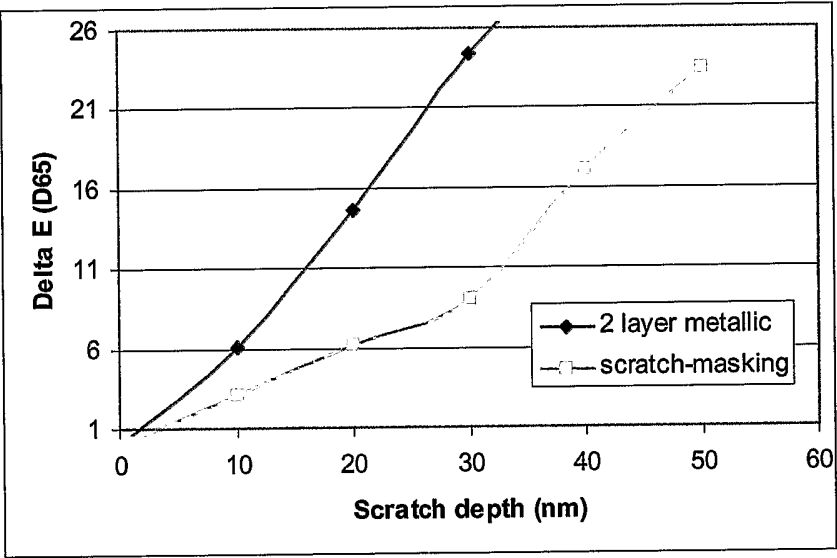
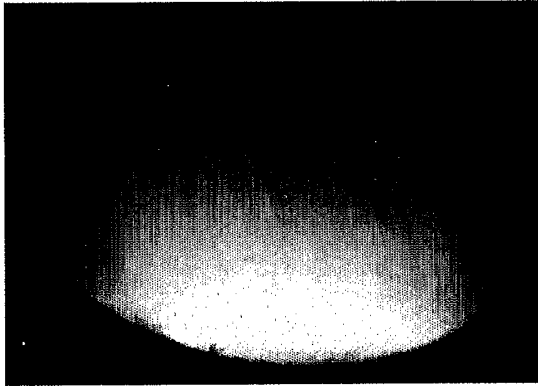
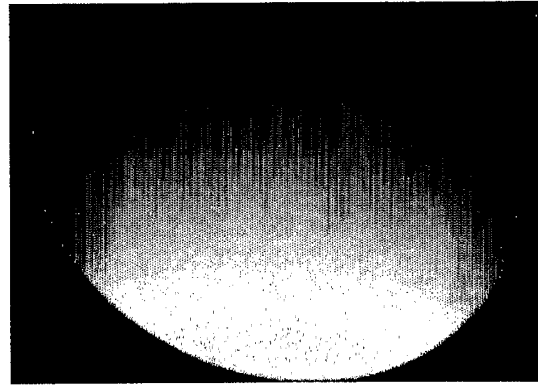


Figure 6



Two layer metallic mirror coating



Scratch masking Sky Blue coating

INTERNATIONAL SEARCH REPORT

International application No.
PCT/AU02/01035

A. CLASSIFICATION OF SUBJECT MATTER												
Int. Cl. ⁷ : G02B 1/10												
According to International Patent Classification (IPC) or to both national classification and IPC												
B. FIELDS SEARCHED												
Minimum documentation searched (classification system followed by classification symbols)												
Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched												
Electronic data base consulted during the international search (name of data base and, where practicable, search terms used) DWPI: IPC G02B 1/10, 1/11, 1/12: keywords; plural, multiple, several, scratch, damage, abra+.												
C. DOCUMENTS CONSIDERED TO BE RELEVANT												
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.										
A	Patent Abstracts of Japan, JP 10-291269 A (OIKE IND CO LTD) 4 November 1998.											
A	Patent Abstracts of Japan, JP 10-170709 A (SHIMADZU CORP) 26 June 1998.											
A	Derwent Abstract Accession No. 87-332298/47, class P81, JP 62-239103 A (ALPS ELECTRIC KK) 20 October 1987.											
☐ Further documents are listed in the continuation of Box C ☒ See patent family annex												
* Special categories of cited documents: <table border="0"> <tr> <td>"A" document defining the general state of the art which is not considered to be of particular relevance</td> <td>"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention</td> </tr> <tr> <td>"E" earlier application or patent but published on or after the international filing date</td> <td>"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone</td> </tr> <tr> <td>"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)</td> <td>"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art</td> </tr> <tr> <td>"O" document referring to an oral disclosure, use, exhibition or other means</td> <td>"&" document member of the same patent family</td> </tr> <tr> <td>"P" document published prior to the international filing date but later than the priority date claimed</td> <td></td> </tr> </table>			"A" document defining the general state of the art which is not considered to be of particular relevance	"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention	"E" earlier application or patent but published on or after the international filing date	"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone	"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)	"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art	"O" document referring to an oral disclosure, use, exhibition or other means	"&" document member of the same patent family	"P" document published prior to the international filing date but later than the priority date claimed	
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Date of the actual completion of the international search 12 September 2002		Date of mailing of the international search report 19 SEP 2002										
Name and mailing address of the ISA/AU AUSTRALIAN PATENT OFFICE PO BOX 200, WODEN ACT 2606, AUSTRALIA E-mail address: pct@ipaustalia.gov.au Facsimile No. (02) 6285 3929		Authorized officer F.C.PEARSON Telephone No : (02) 62832195										

INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No.

PCT/AU02/01035

This Annex lists the known "A" publication level patent family members relating to the patent documents cited in the above-mentioned international search report. The Australian Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

Patent Document Cited in Search Report		Patent Family Member
JP	10291269	NONE
JP	10170709	NONE
JP	62239103	NONE
		END OF ANNEX